



Heat transfer at a sapphire – indium interface in the 30 mK – 300 mK temperature range

J. Liberadzka^{1,3}, T. Koettig¹, J. Bremer¹, C. C. W. van der Post²
and H. J. M. ter Brake³

¹CERN, Switzerland,

²Fontys School of Natural Sciences, Netherlands

³University of Twente, Netherlands

Content

- Motivation – AEgIS
- Dilution Refrigerator
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- Results
- Conclusions

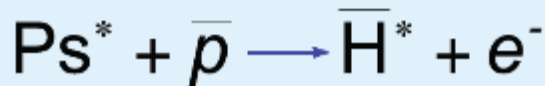
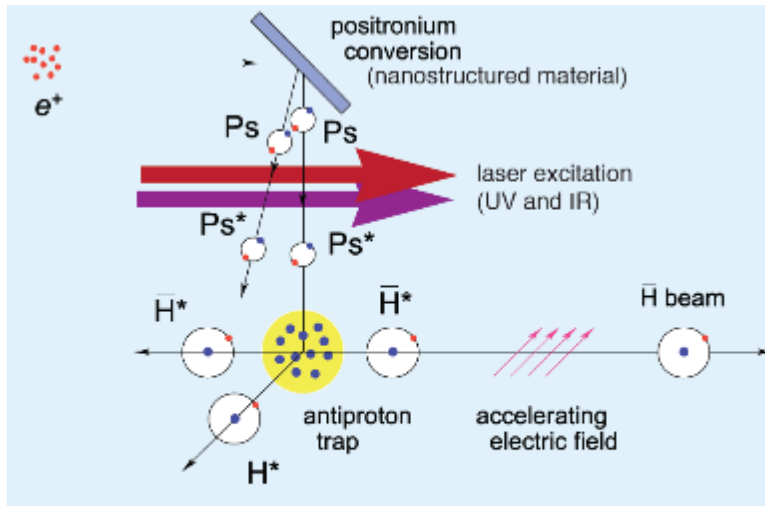
AEgIS:

Antimatter Experiment: Gravity, Interferometry, Spectroscopy

Goal:

direct measurement of the Earth's gravitational acceleration g on antihydrogen within 1% accuracy

Antihydrogen formation:



Galileo, Pisa, 1589

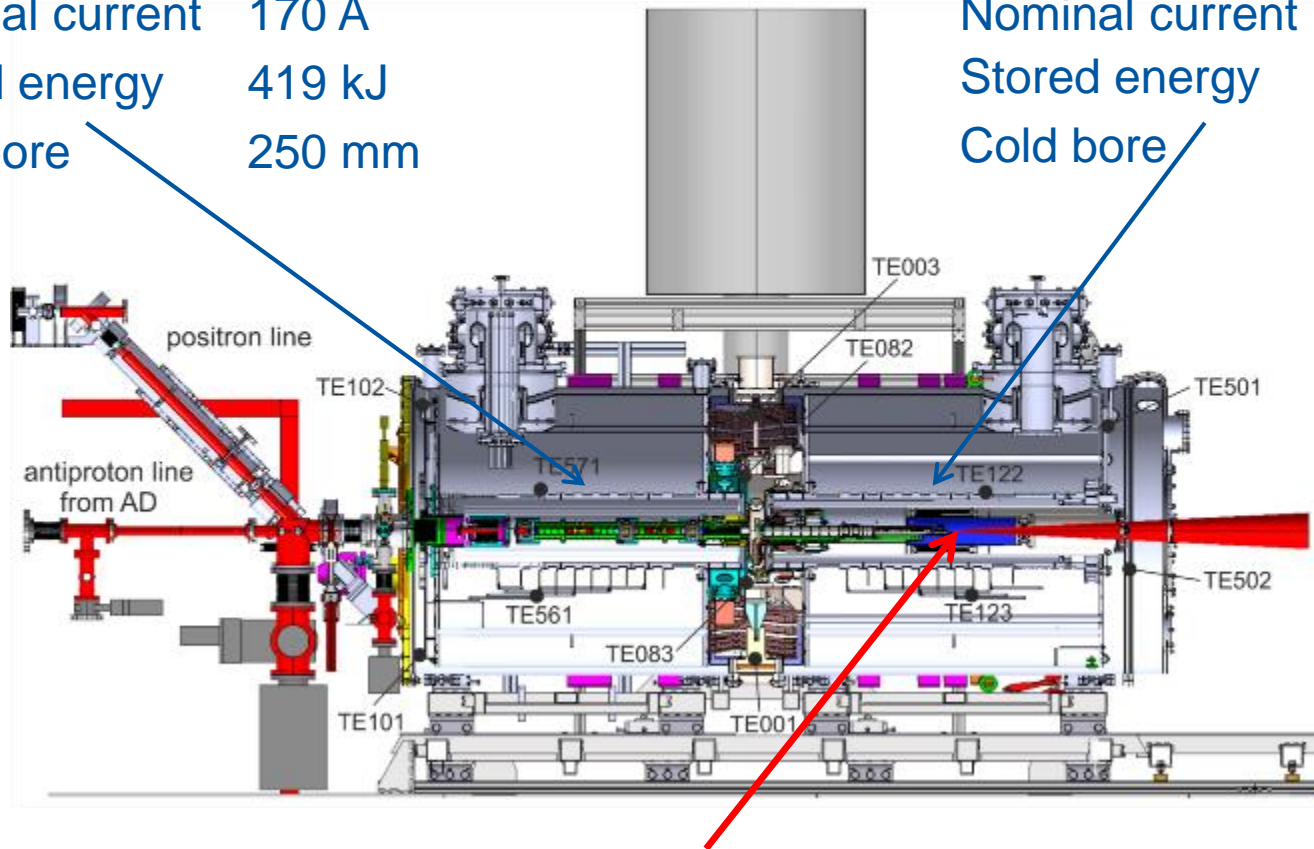
AEgIS apparatus lay-out

5T-magnet

Nominal current 170 A
Stored energy 419 kJ
Cold bore 250 mm

1T-magnet

Nominal current 85A
Stored energy 29 kJ
Cold bore 160 mm



Antihydrogen in a Penning trap below 100 mK

Ultra-Cold Electrodes

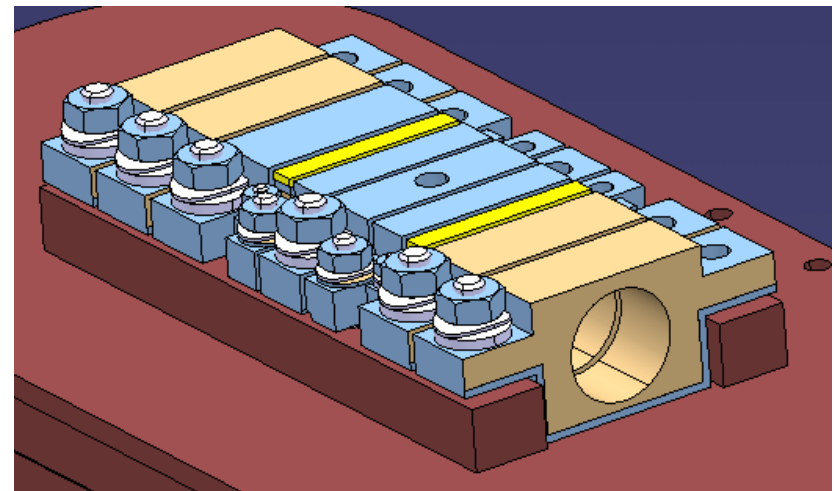
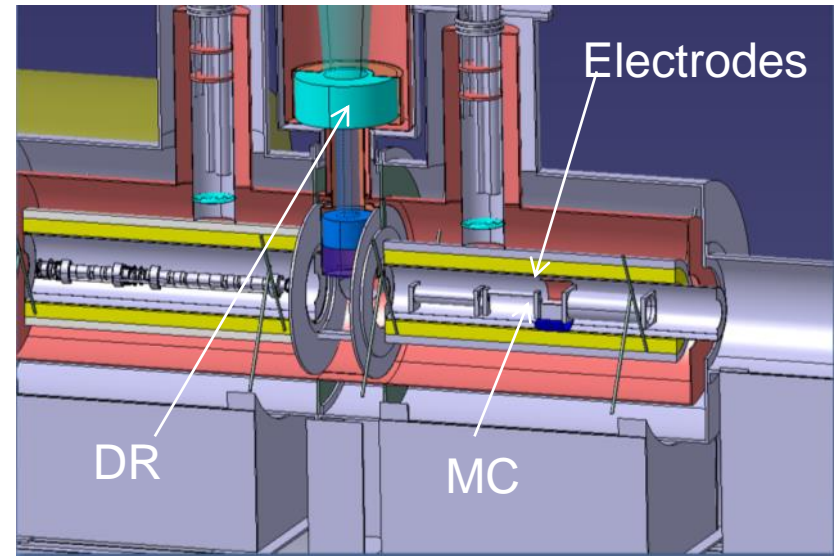
- 10 electrodes cooled to 100 mK
- Made of radiation hard materials
- Ultra-high vacuum ($< 10^{-12}$ mbar)
- Electrical insulation for up to 1kV between neighbouring electrodes
- geometry with very high precision



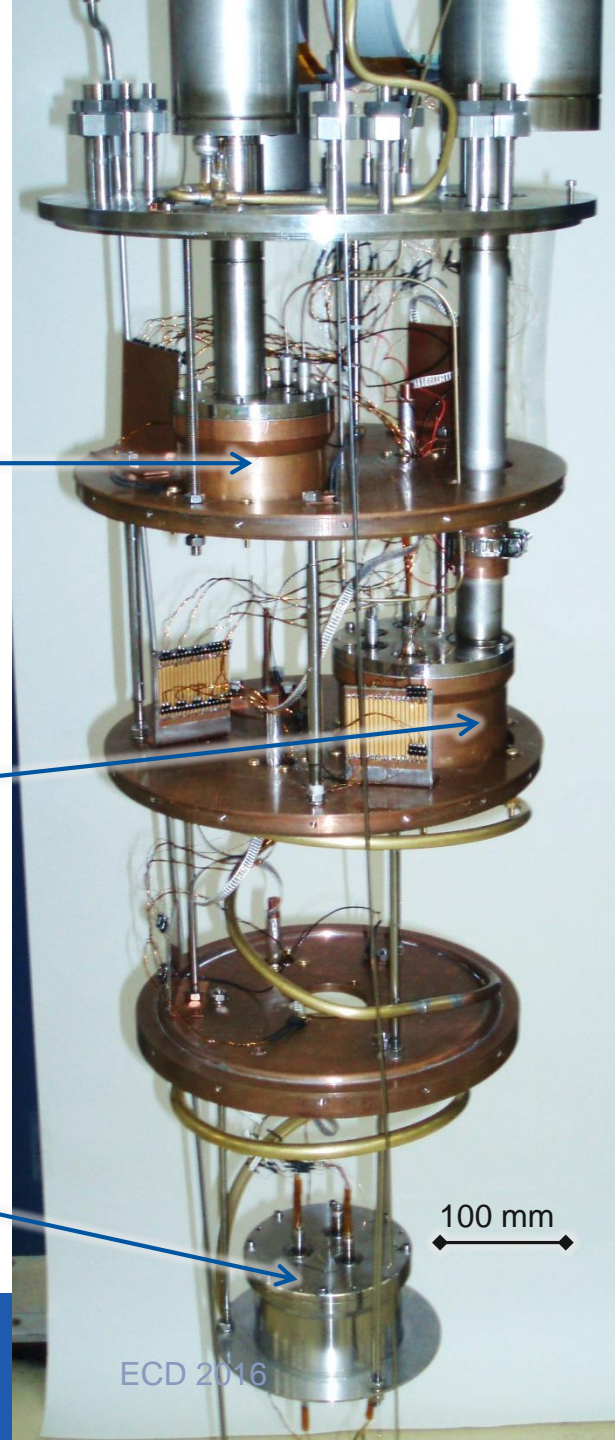
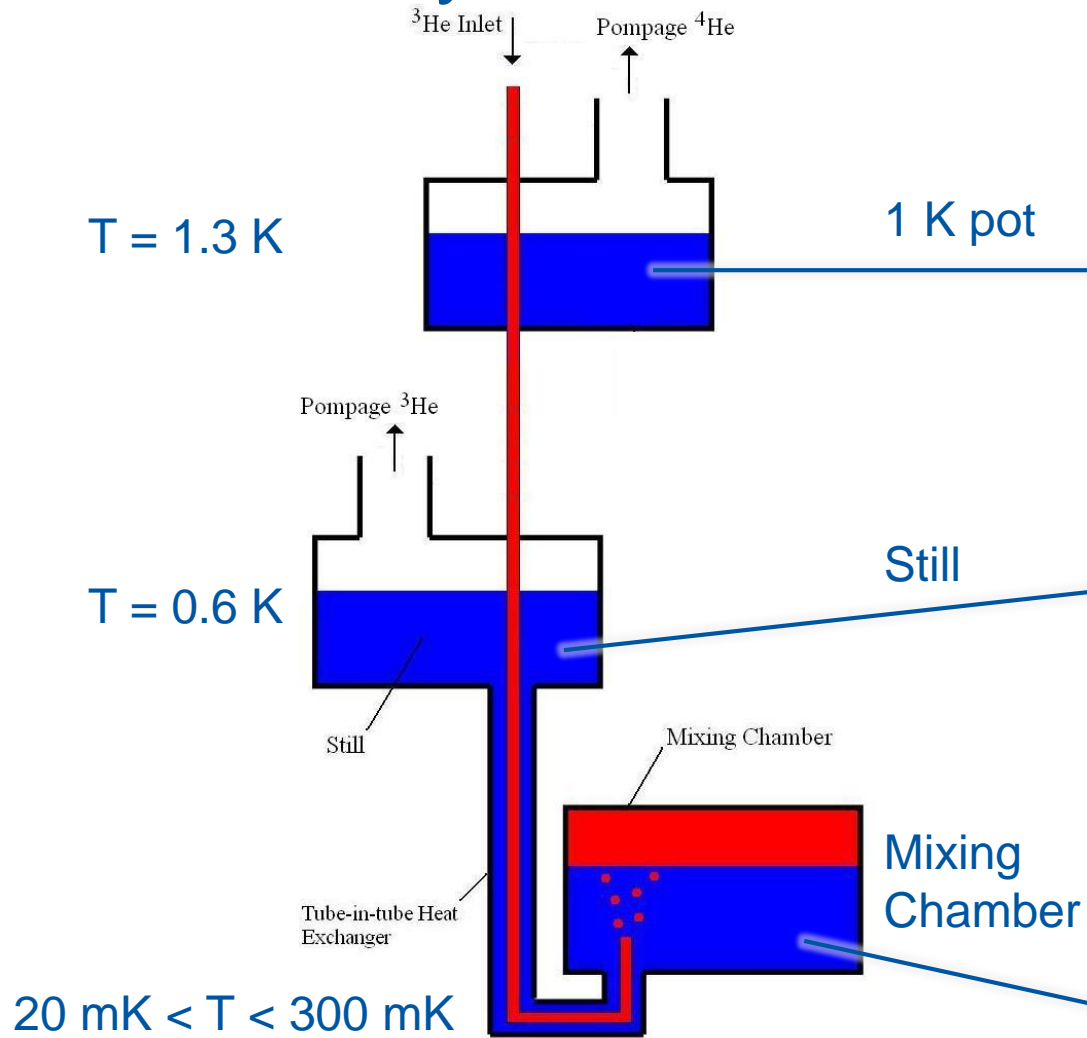
Sapphire as electrical insulator and good thermal conductor at low temperature



Thermal performance of a metal – dielectric Interface to be studied in 30 – 300 mK range



CERN Cryolab DR

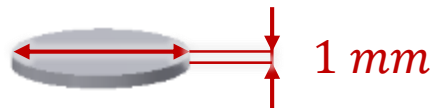


Pictures by Patrick Wikus

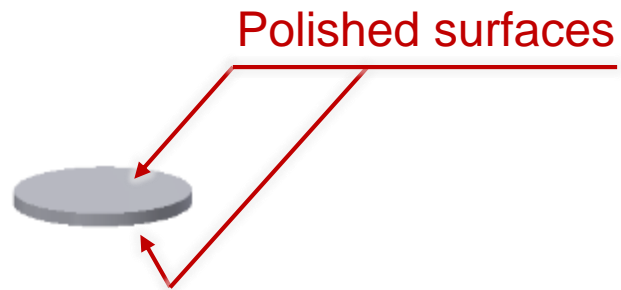
Experimental setup

Sapphire disk

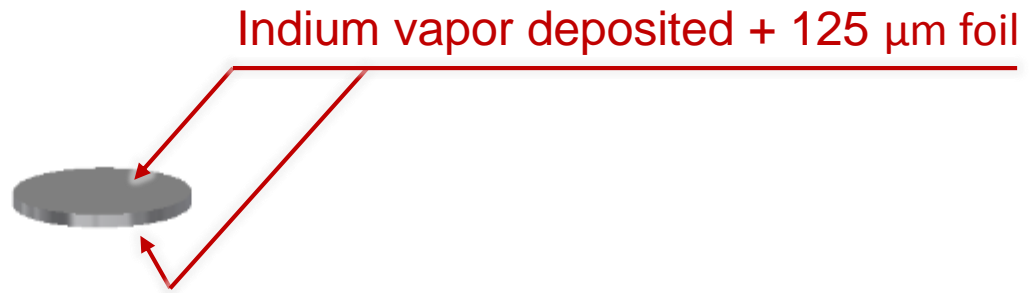
$\phi = 20 \text{ mm}$



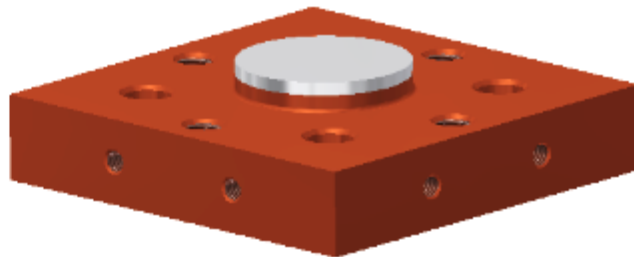
Experimental setup



Experimental setup



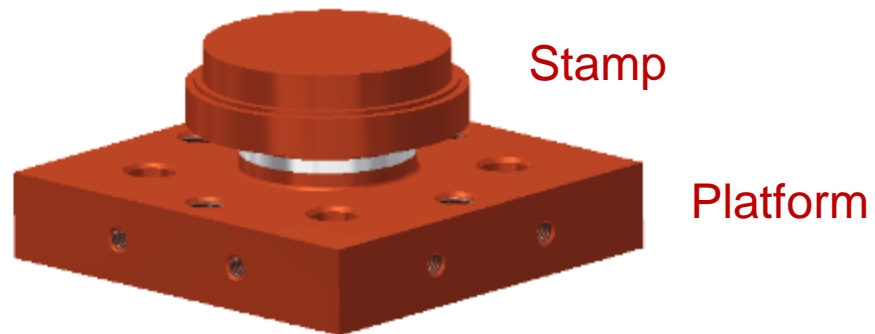
Experimental setup



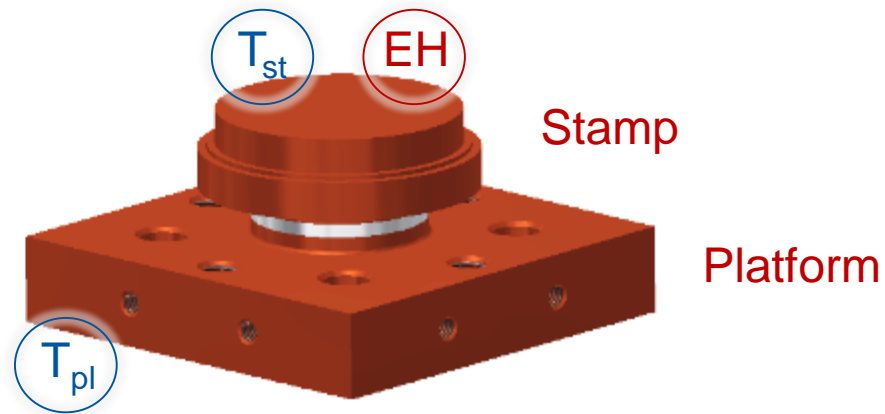
Platform



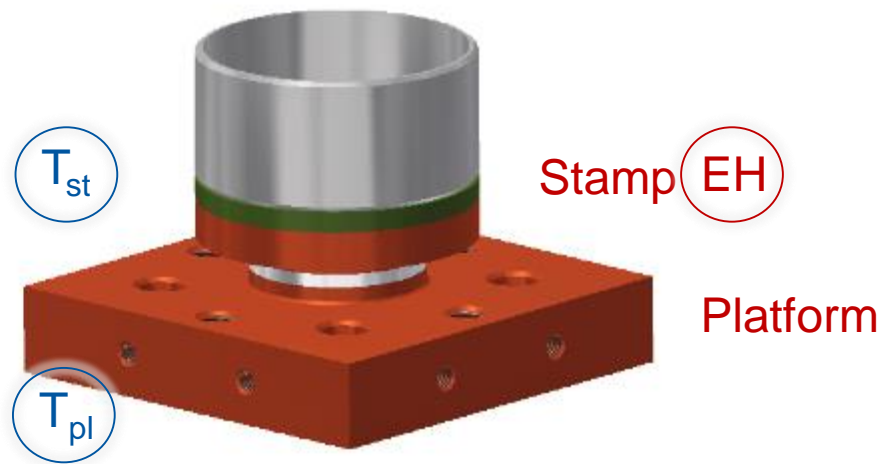
Experimental setup



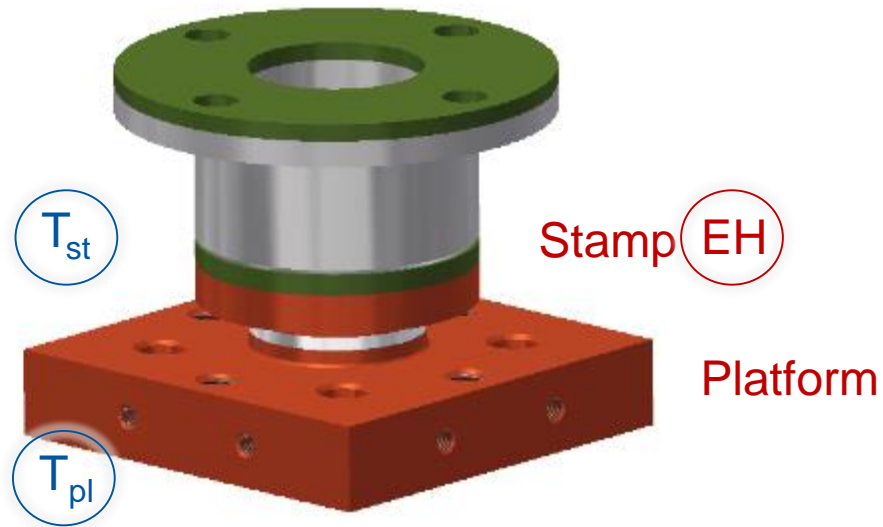
Experimental setup



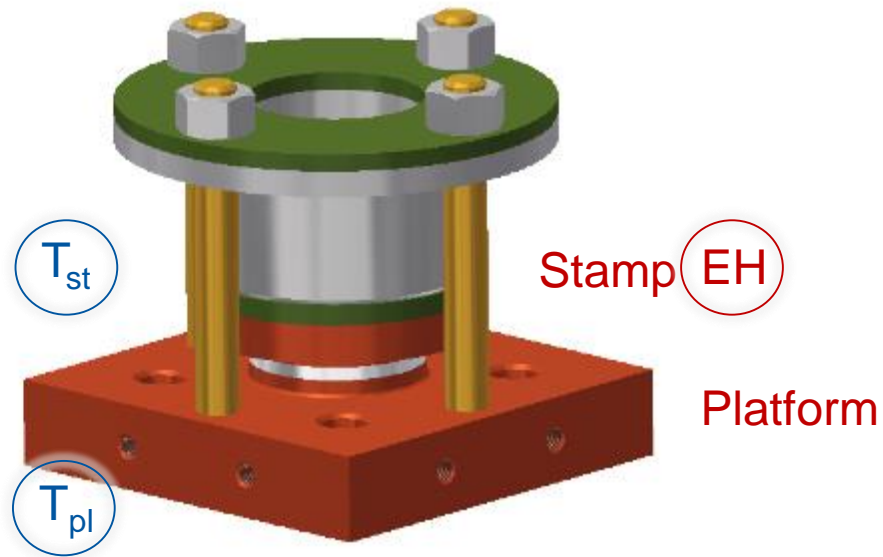
Experimental setup



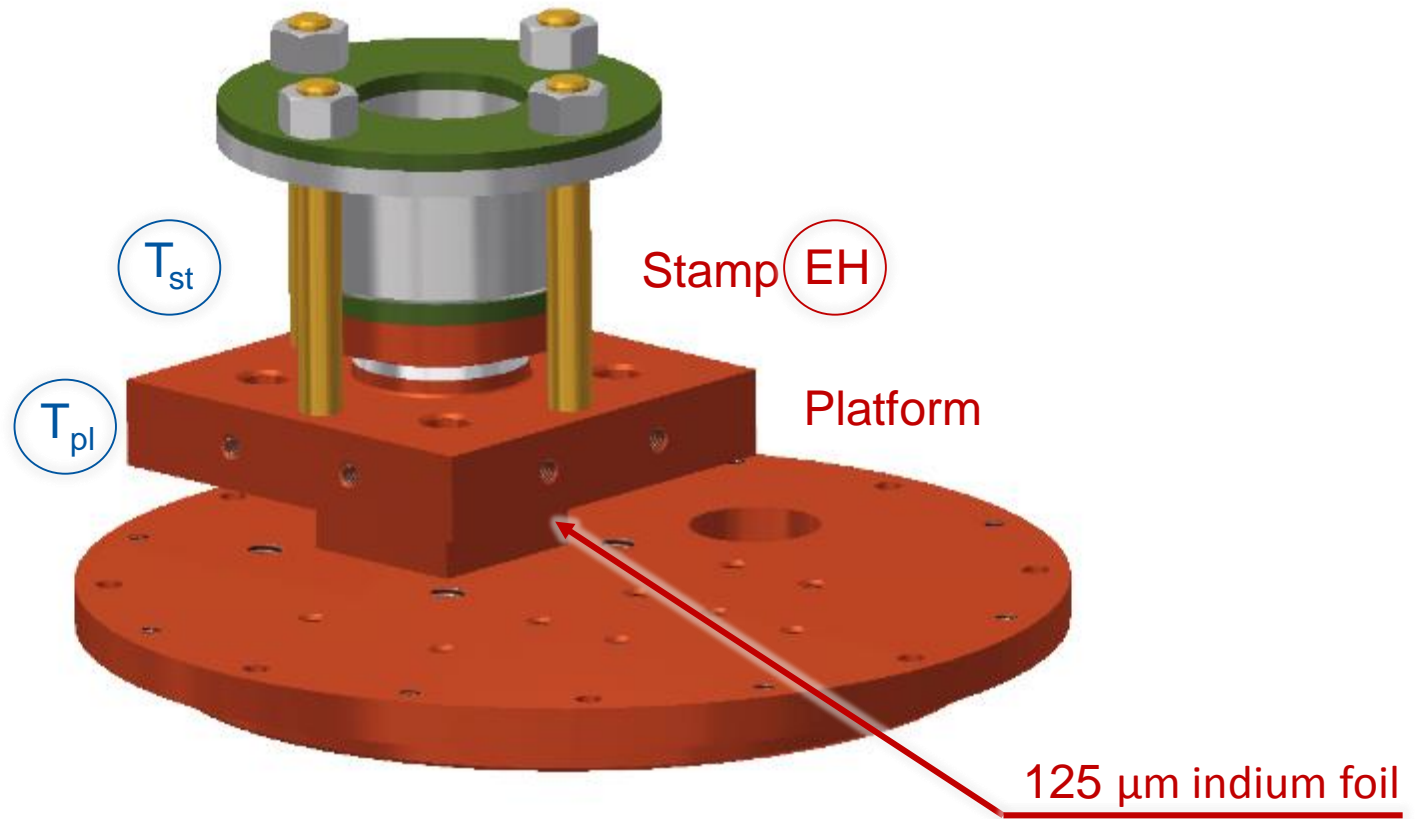
Experimental setup



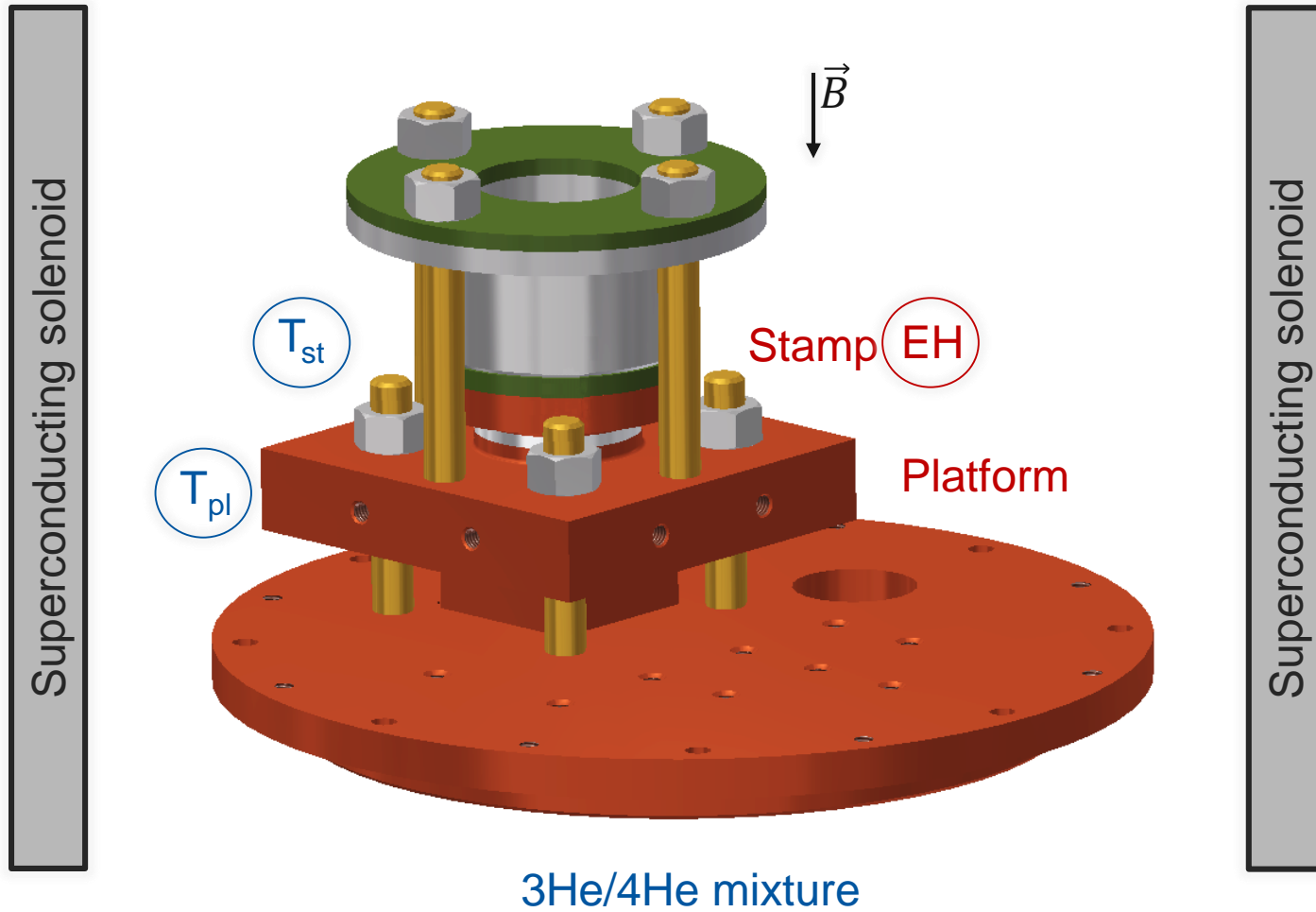
Experimental setup



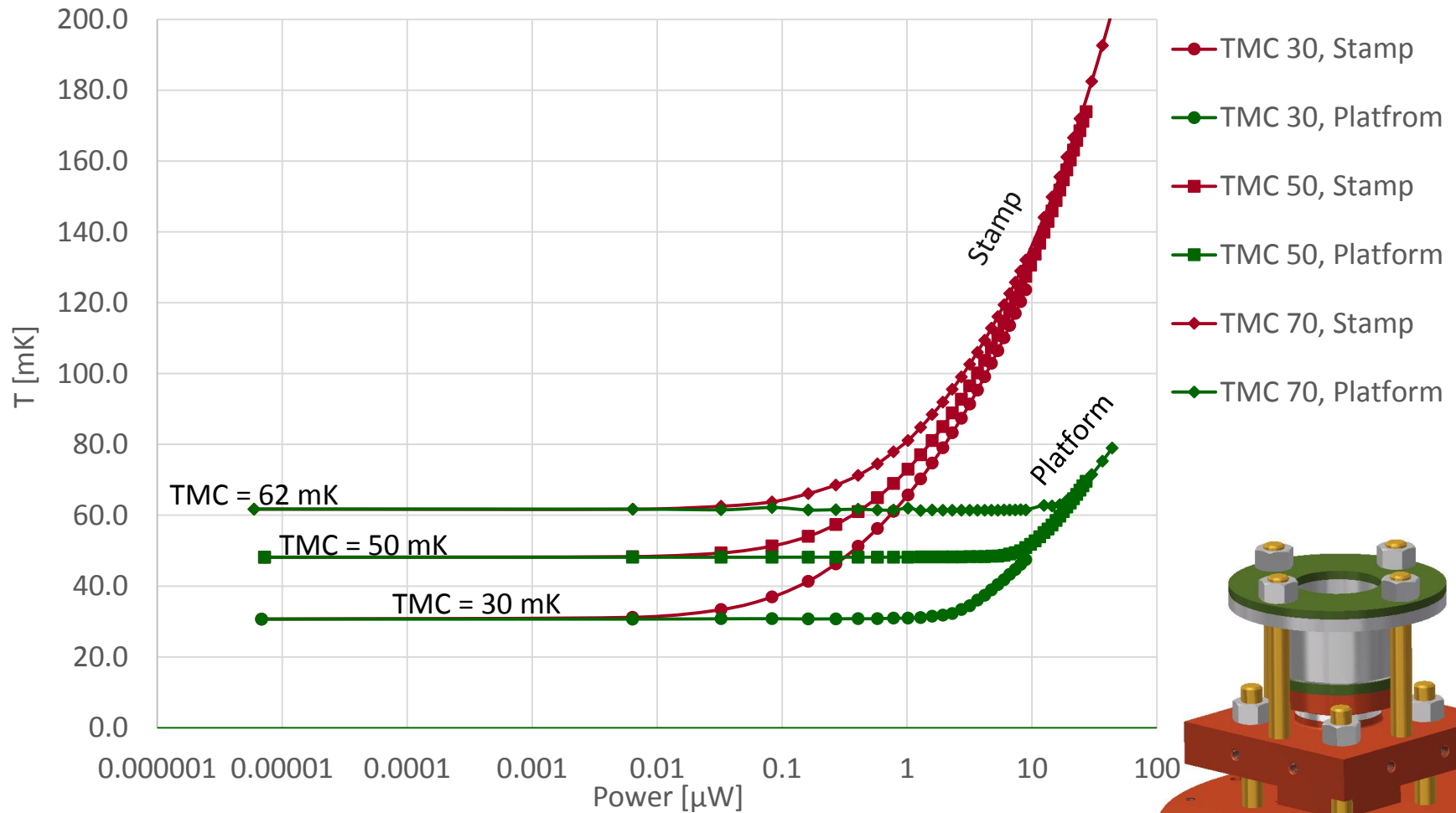
Experimental setup



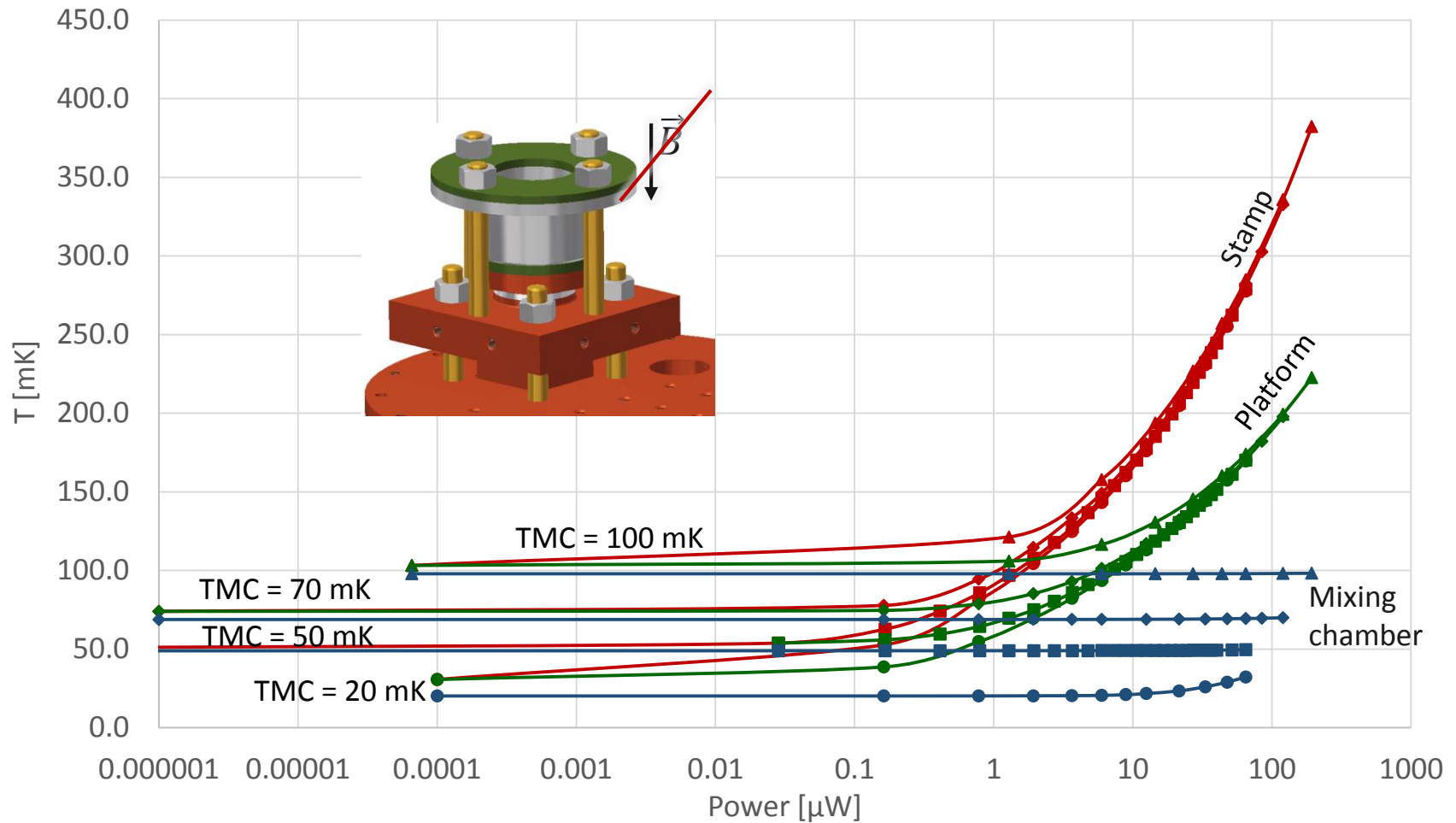
Experimental setup



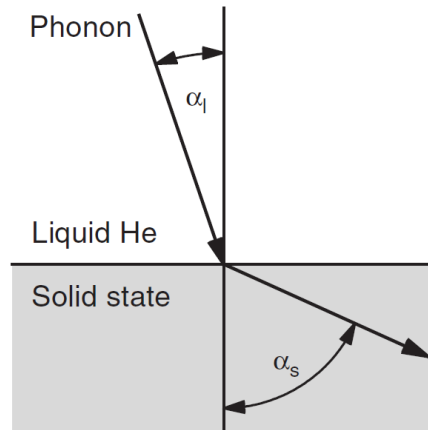
Temperature as a function of applied heat load, Indium in normal conducting state



Temperature as a function of applied heat load, Indium in superconducting state



Kapitza resistance



Ch. Enss, S.Hunklinger – Low-Temperature Physics

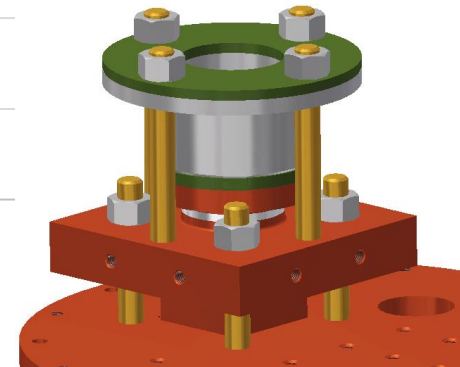
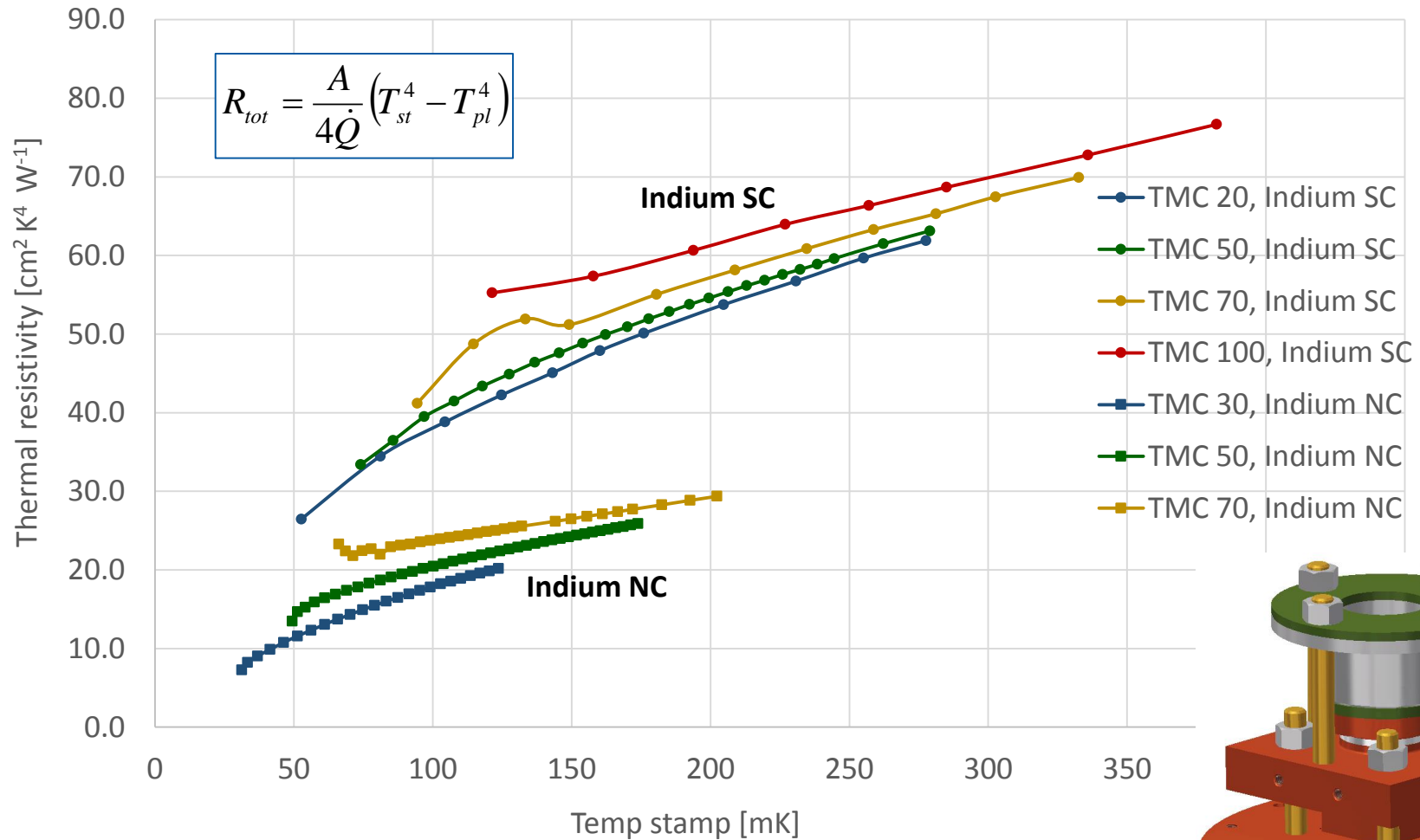
$$R_{tot} = \frac{A}{4\dot{Q}} (T_{st}^4 - T_{pl}^4)$$

$$\alpha = 4^\circ$$
$$t = \frac{4Z_1Z_2}{(Z_1 + Z_2)^2}$$

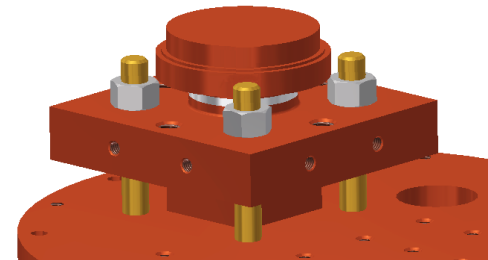
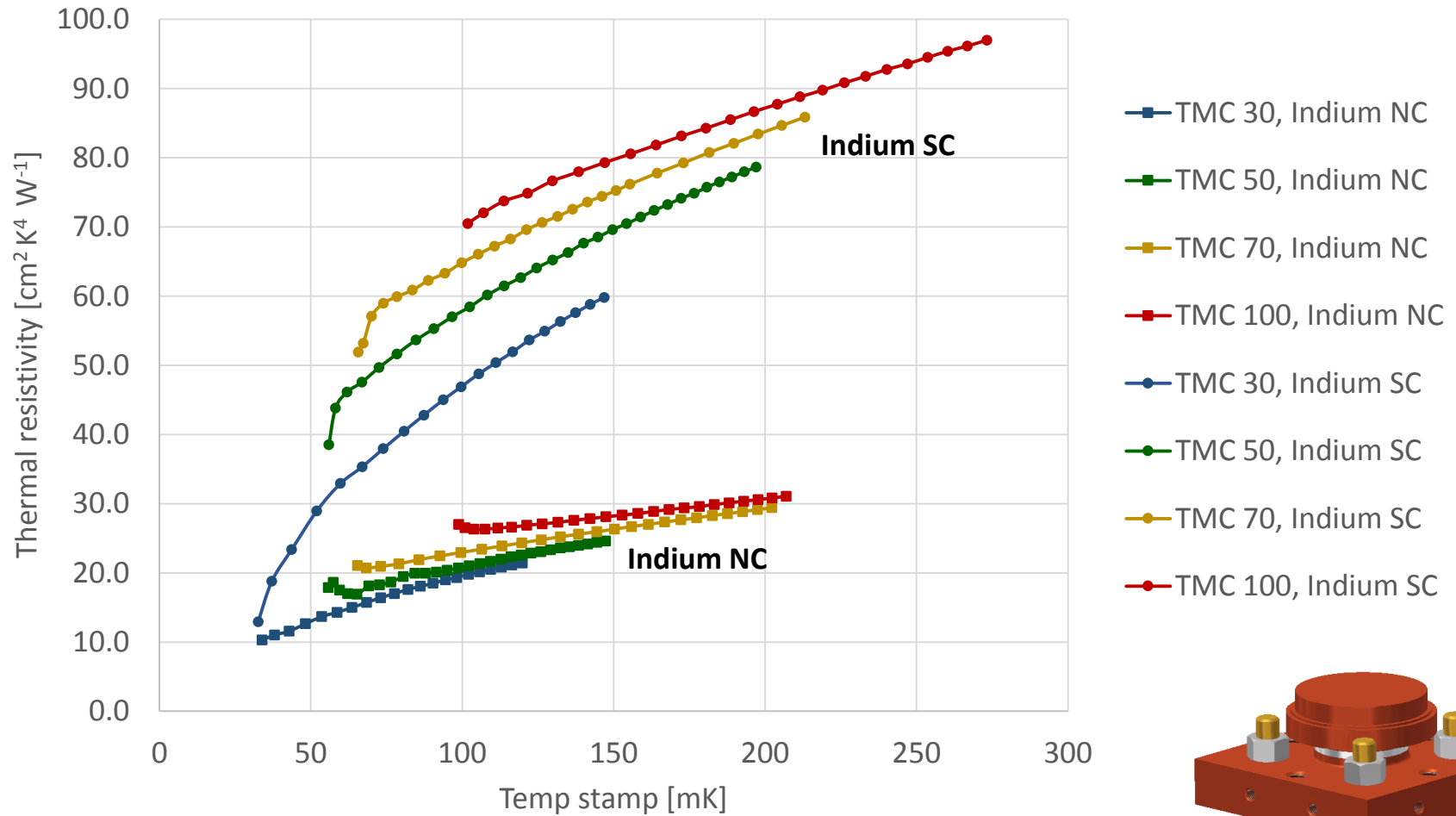


helium – copper
only 10^{-5}

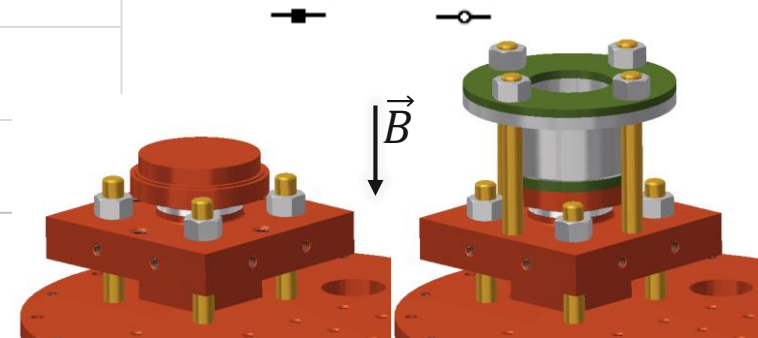
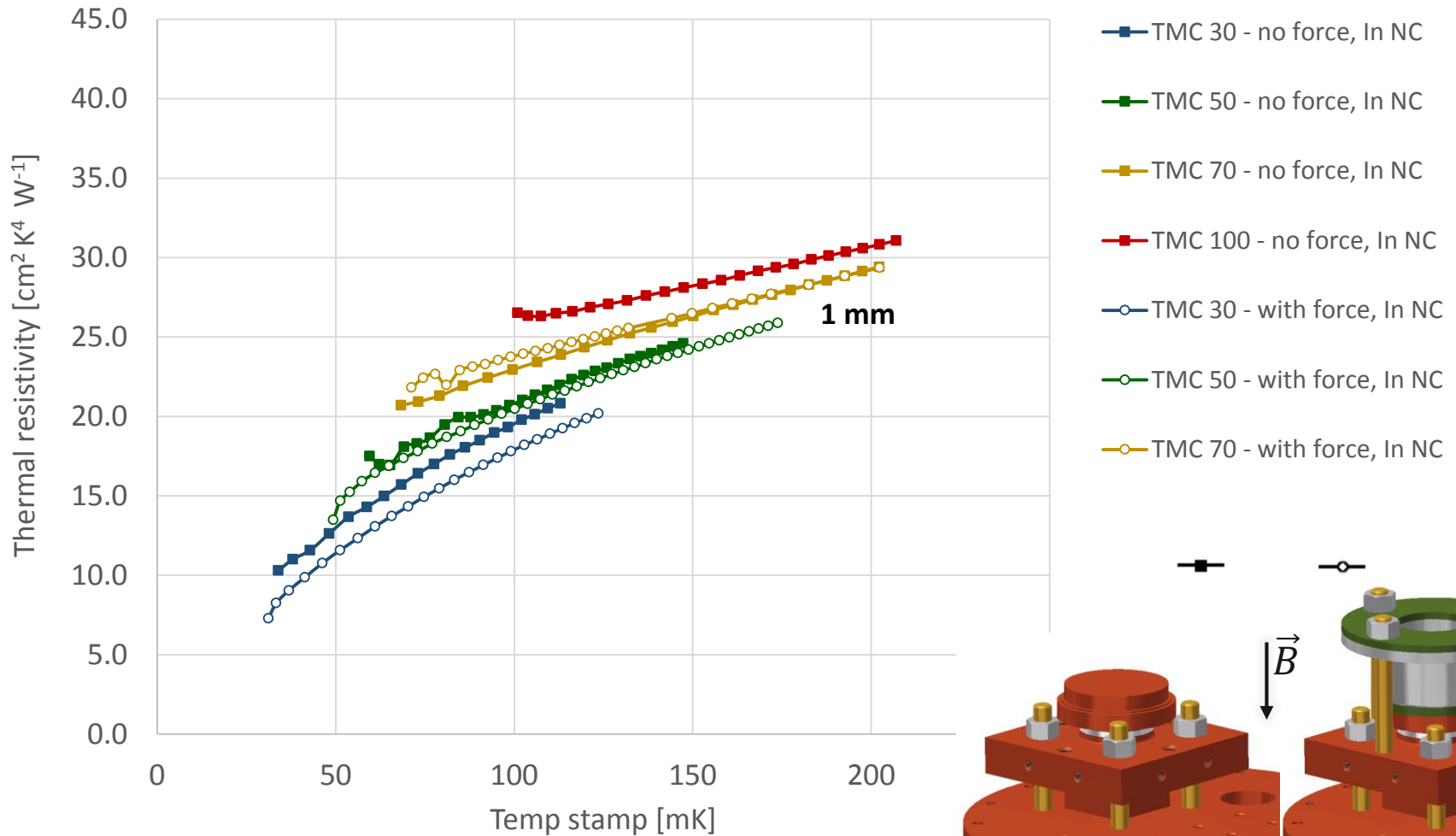
Thermal resistivity of the compressed setup



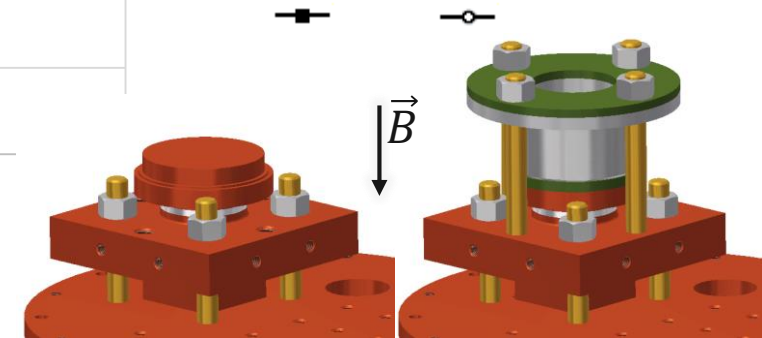
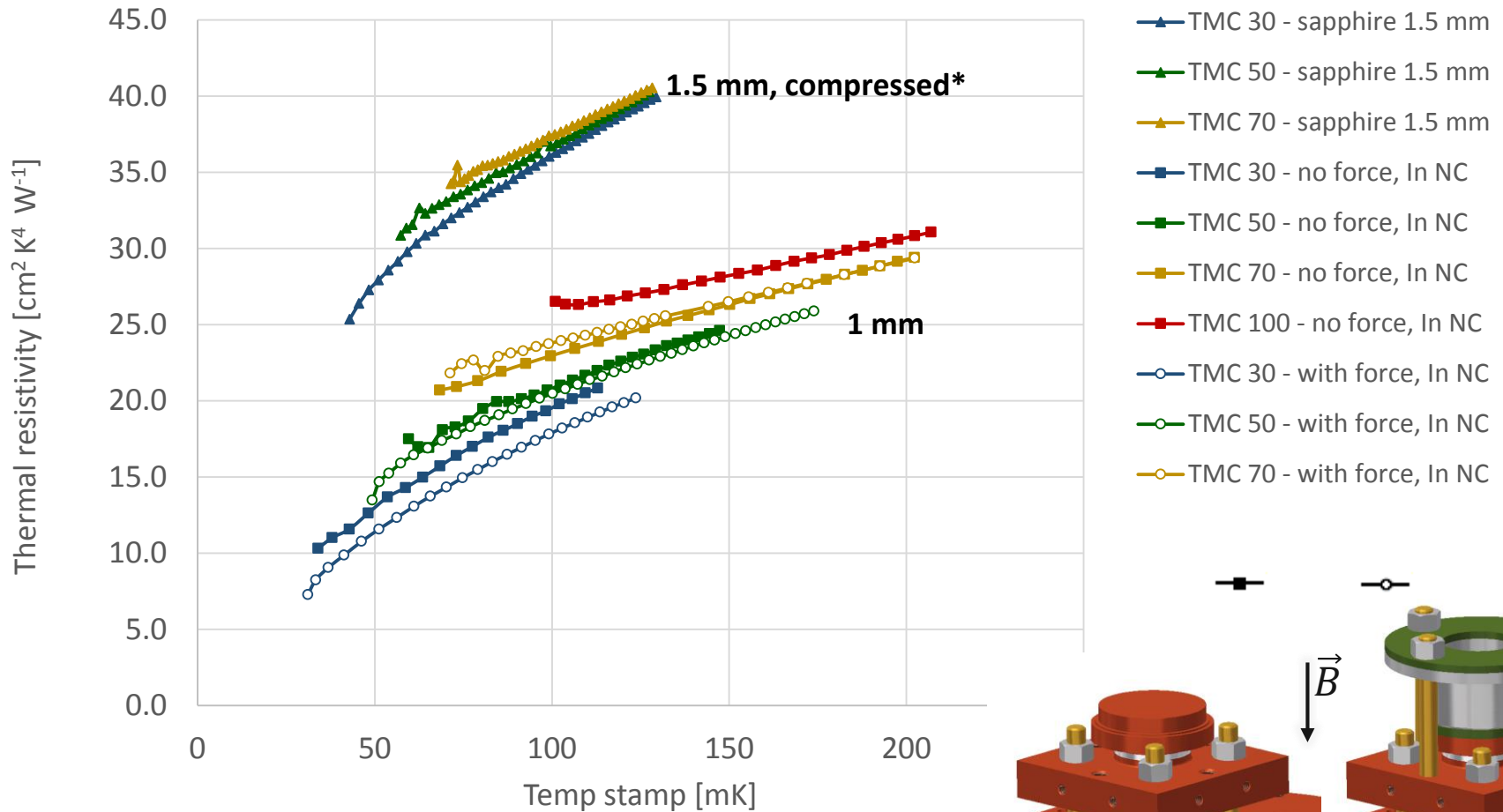
Thermal resistivity without compressing force



Thermal resistivity with NC indium



Thermal resistivity of the setup with 1 mm and 1.5 mm sapphire disk with NC indium



*Courtesy T. Eisel, PhD Thesis, CERN, Cryolab

Conclusions

- Surface preparation essential – polished surface with vapor deposited indium gives the best results
- The presence of the magnetic field shifts the dielectric – metallic interface and significantly changes the overall resistivity
- Compressing force doesn't influence the results with indium in normal conducting state
- The electrode mounting structure in AEgIS can be removed after a good connection is obtained

